



Applications of Transparent Metal Mesh Nanostructures

Themis Kallos, Chief Science Officer, Meta Materials Inc.

20th April 2022AD



Forward Looking Statements

This presentation includes forward-looking information or statements within the meaning of Canadian securities laws and within the meaning of Section 27A of the Securities Act of 1933, as amended, Section 21E of the Securities Exchange Act of 1934, as amended, and the Private Securities Litigation Reform Act of 1995, regarding the Company, which may include, but are not limited to, statements with respect to the business strategies, product development, expansion plans and operational activities of the Company. Often but not always, forward-looking information can be identified by the use of words such as “pursuing”, “potential”, “predicts”, “projects”, “seeks”, “plans”, “expect”, “intends”, “anticipated”, “believes” or variations (including negative variations) of such words and phrases, or statements that certain actions, events or results “may”, “could”, “should”, “would” or “will” be taken, occur or be achieved. Such statements are based on the current expectations and views of future events of the management of the Company and are based on assumptions and subject to risks and uncertainties. Although the management of the Company believes that the assumptions underlying these statements are reasonable, they may prove to be incorrect. The forward-looking events and circumstances discussed in this release may not occur and could differ materially as a result of known and unknown risk factors and uncertainties affecting the Company, the capabilities of our facilities and the expansion thereof, research and development projects of the Company, the market potential of the products of the Company, the market position of the Company, the scalability of the Company’s production ability, capacity for new customer engagements, material selection programs timeframes, the ability to

reduce production costs, enhance metamaterials manufacturing capabilities and extend market reach into new applications and industries, the ability to accelerate commercialization plans, the possibility of new customer contracts, the continued engagement of our employees, the technology industry, market strategic and operational activities, and management’s ability to manage and to operate the business. More details about these and other risks that may impact the Company’s businesses are described under the heading “Forward-Looking Information” and under the heading “Risk Factors” in the Company’s Form 10-Q filed with the SEC on November 15, 2021, in the Company’s Form 10-K filed with the SEC on March 18, 2021, and in subsequent filings made by Meta Materials with the SEC, which are available on SEC’s website at www.sec.gov. Although the Company has attempted to identify important factors that could cause actual actions, events or results to differ materially from those described in forward-looking statements, there may be other factors that cause actions, events or results to differ from those anticipated, estimated or intended. Accordingly, readers should not place undue reliance on any forward-looking statements or information. No forward-looking statement can be guaranteed. Except as required by applicable securities laws, forward-looking statements speak only as of the date on which they are made and the Company does not undertake any obligation to publicly update or revise any forward-looking statement, whether as a result of new information, future events, or otherwise, except to the extent required by law. Unless otherwise stated, all references to \$ herein are to US dollars.



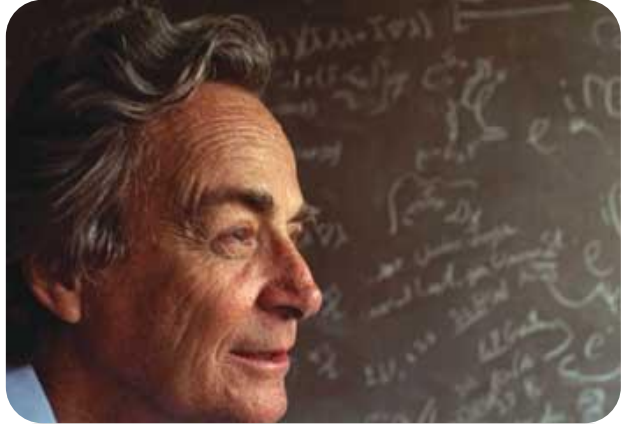
We are Hiring!

metamaterial.com/careers

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Go Beyond.

Outline

- About META
- META Applications
- Focus Application: Transparent Redirectors for Communications
 - The Problem
 - Technology: Nanoweb
 - Solution
- Manufacturing at Scale



*“I can’t see what exactly would
happen,*

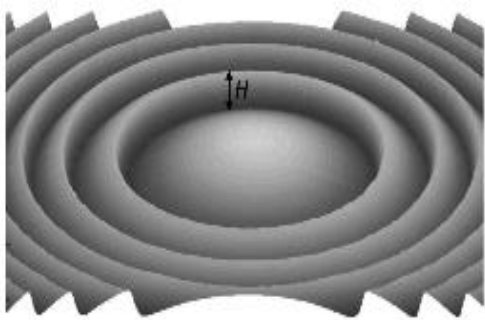
*but when we have some control of
the arrangement of things in the
small scale,*

*we will get an enormously greater
range of possible properties that
substances can have.”*

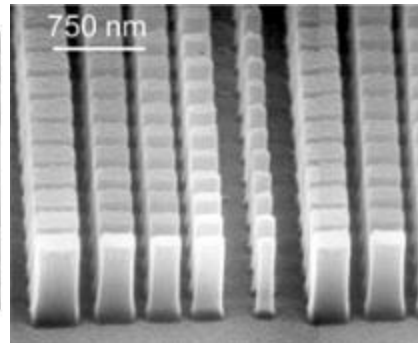
1959

The “Age of Invisible Materials”

Échelette DOE
(1970's)



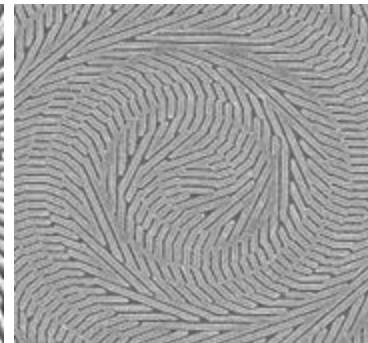
Blazed binary grating
(1998)



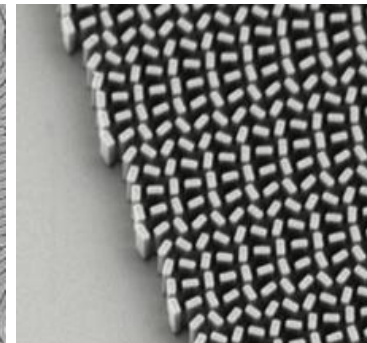
Geometric Phase
(2001)



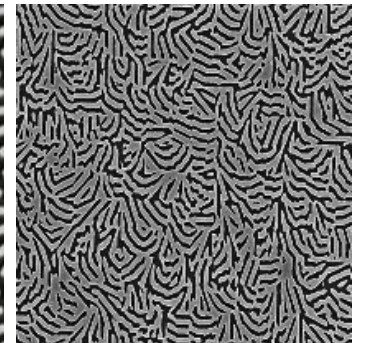
Mie resonators
(2014)



High performance
(2016)



Light field
(2019)



About META

META[®]
Go Beyond.



The META Timeline

2021	1 st Metamaterial Company on NASDAQ
2011	META Founded (London, UK)
2000	Negative Refraction Demonstrated
1968	Veselago's Paper
1865	Maxwell's Equations
1492 AD	America Discovered
55 BCE	Romans invade Britain
776 BCE	First Olympiad
3000 BCE	Great Pyramid Built
10,000 BCE	Farming
200,000 BCE	Early Humans

Global Presence



Halifax, Nova Scotia, Canada

Global HQ
R&D and Integrated Applications
Product Dev. & Low vol. mfg.

Burnaby, BC, Canada

Product Design and R&D

Thurso, QC, Canada

Global Manufacturing HQ
High Vol. Manufacturing

Boxborough, MA, USA

USA Headquarters

Pleasanton, California, USA

NA Sales
Product Design and R&D

Tokyo, Japan

Japan/APAC Sales

London & Oxford, UK

UK/EU Sales
Research & Development

Athens, Greece

EU Sales
Product Design and

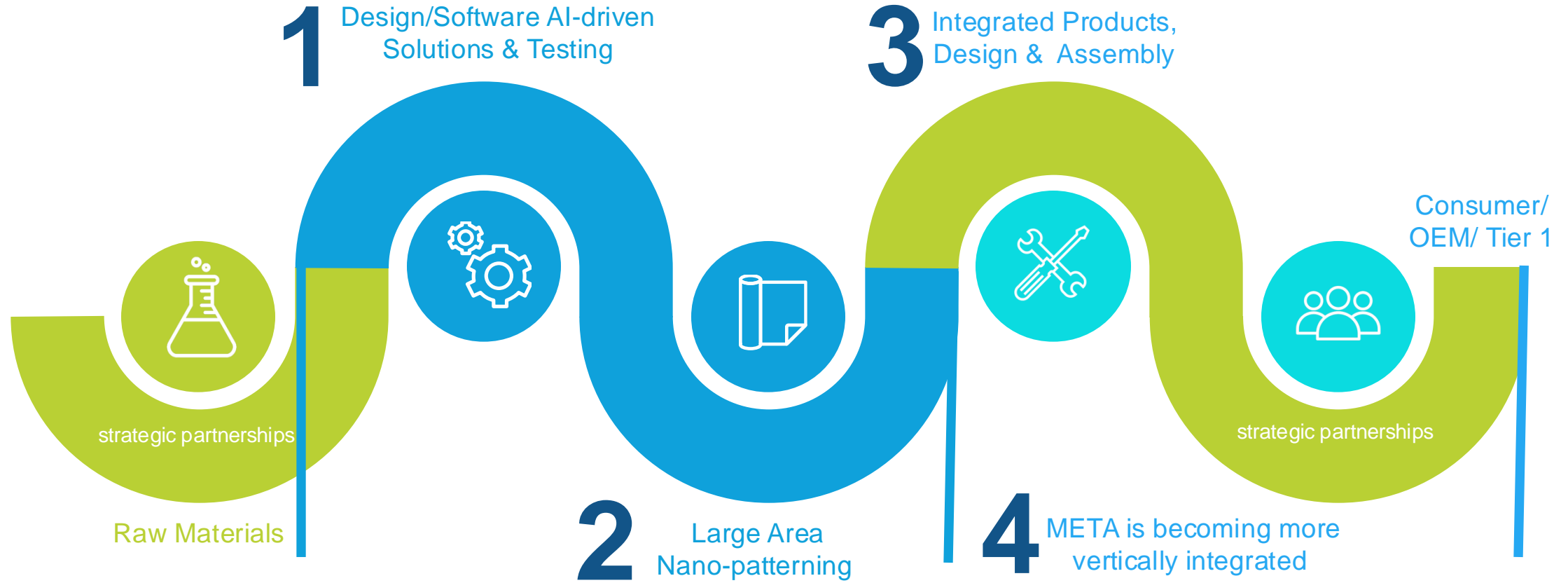
OEM Partners & Customers: Solving Global Challenges Together

META[®]

Select Targeted Co-Development Partners and Customers in Automotive, Medical, Aerospace & Defense, Consumer Electronics and Energy



META Solution Provider in the Value Chain



Intellectual Property & Know-How

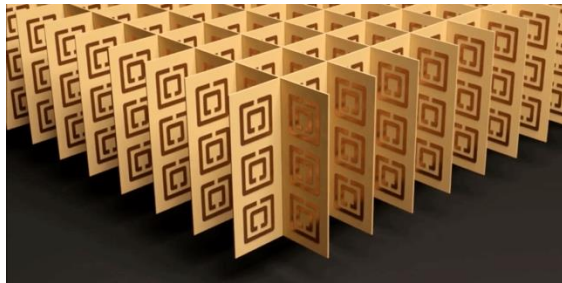
269

active utility and design patent documents



37

issued patents and 26 pending applications in the U.S.

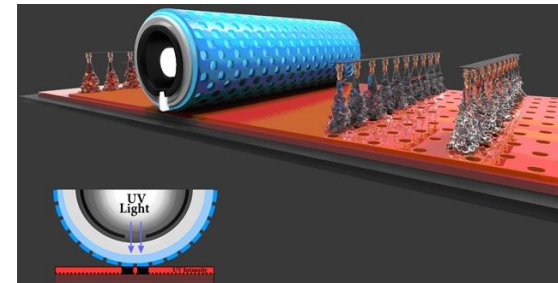


9

registered trademarks

6

design patent applications



UTILITY PATENT DOCUMENTS

- 164** Devices & Components
- 65** Scaled Manufacturing
- 34** Fabrication & Origination

163

utility patents have issued 74 patent families



126

issued patents and 80 pending applications in 24 other countries

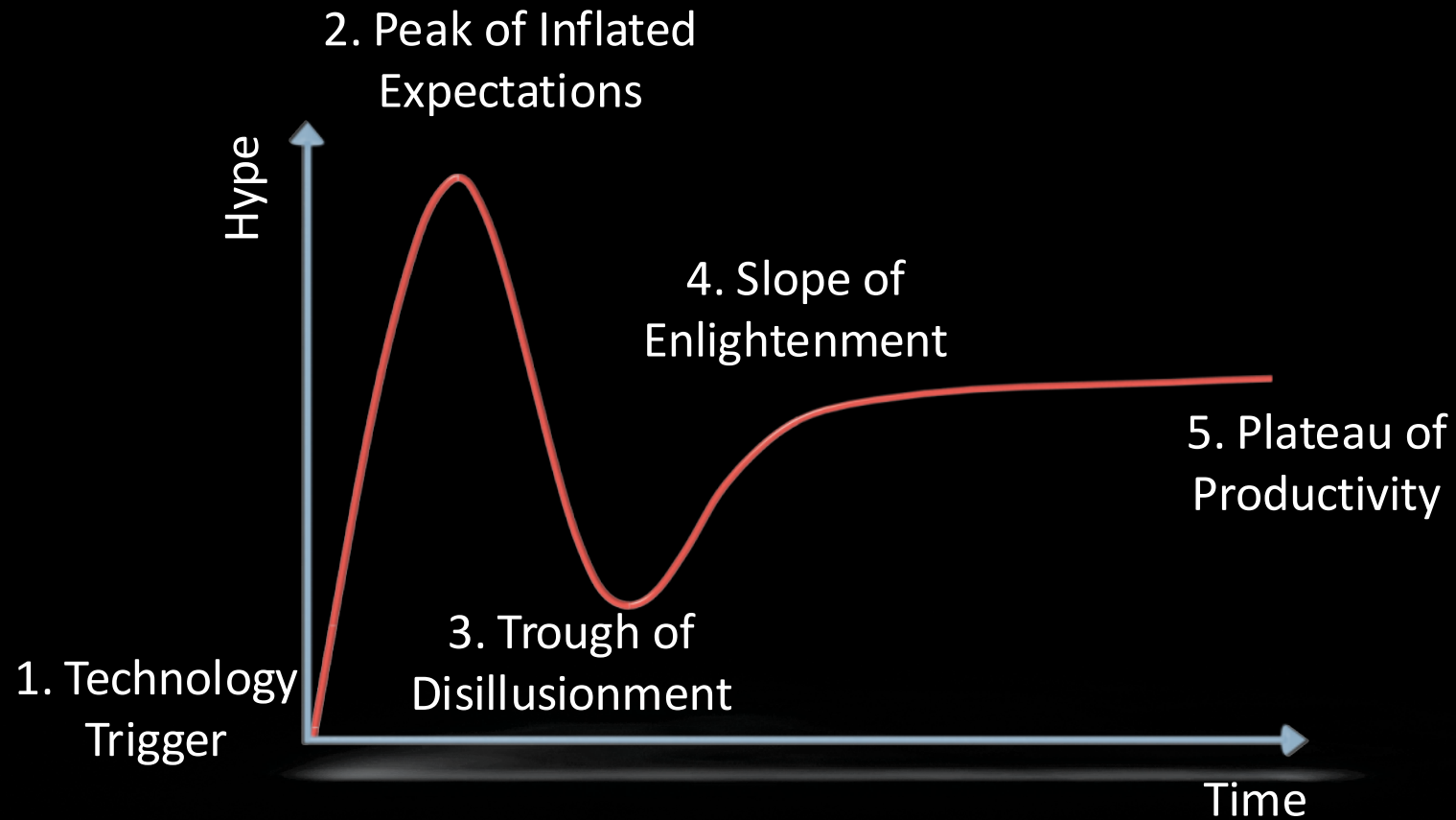


Metamaterials 2014

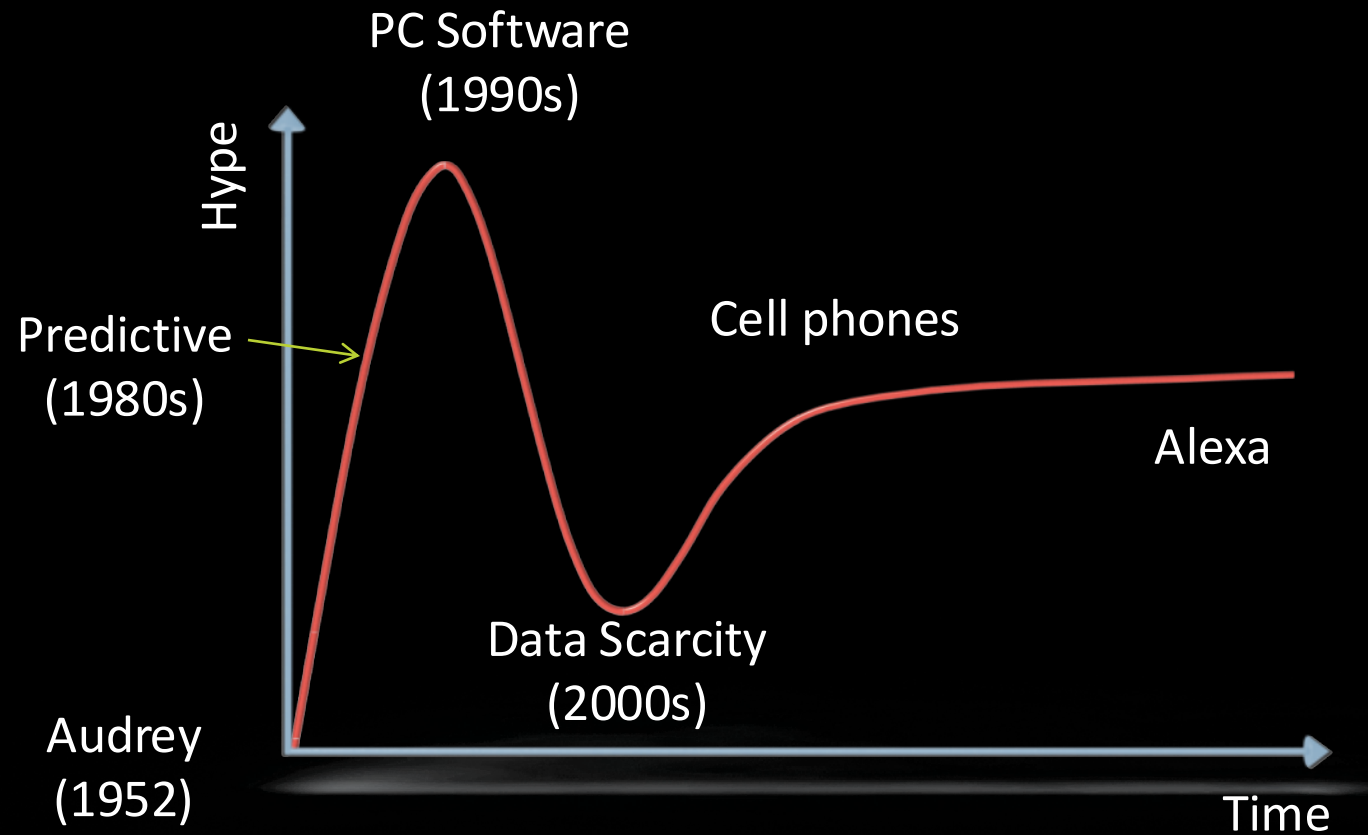
Copenhagen, Denmark

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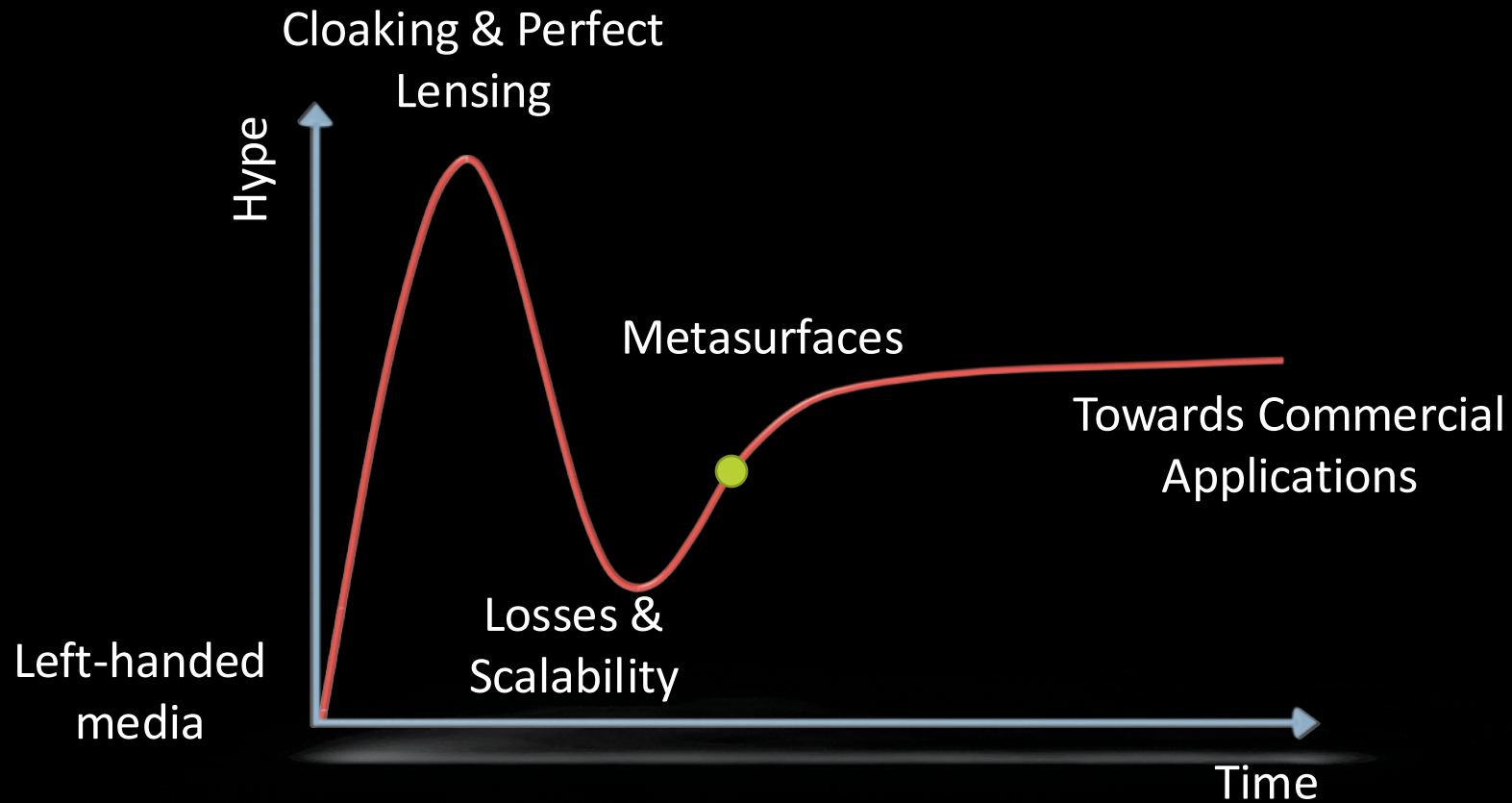
The Gartner Hype Cycle



The Hype Cycle – Speech Recognition



The Hype Cycle for Commercial Metamaterials



- Transparency for visible applications
- Large scale nanofabrication
nm accuracy over meter-long surfaces
- Cost-effective fabrication
\$1-10 per cm² on volume production

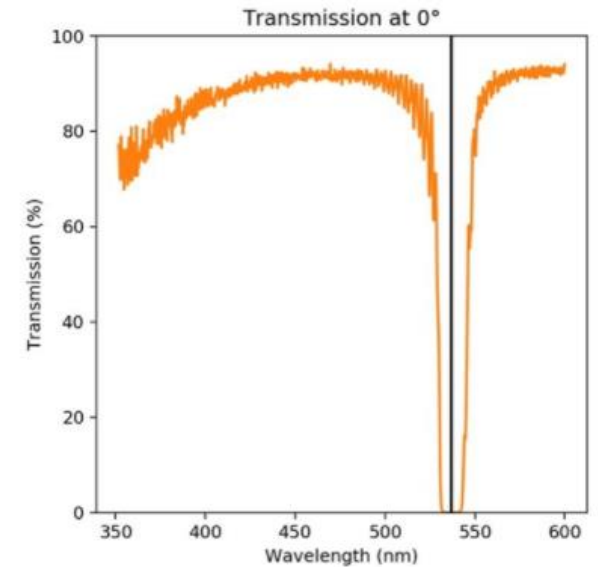
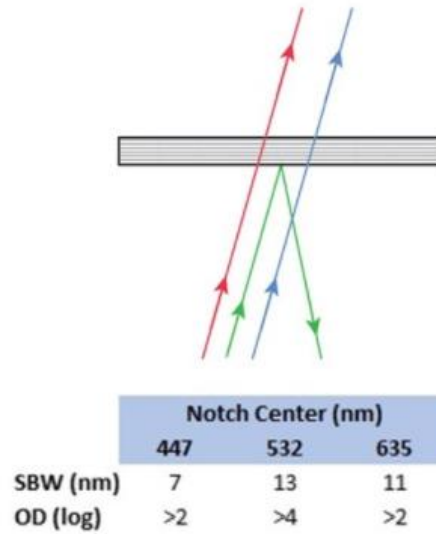
META Applications

Functional Films for the People

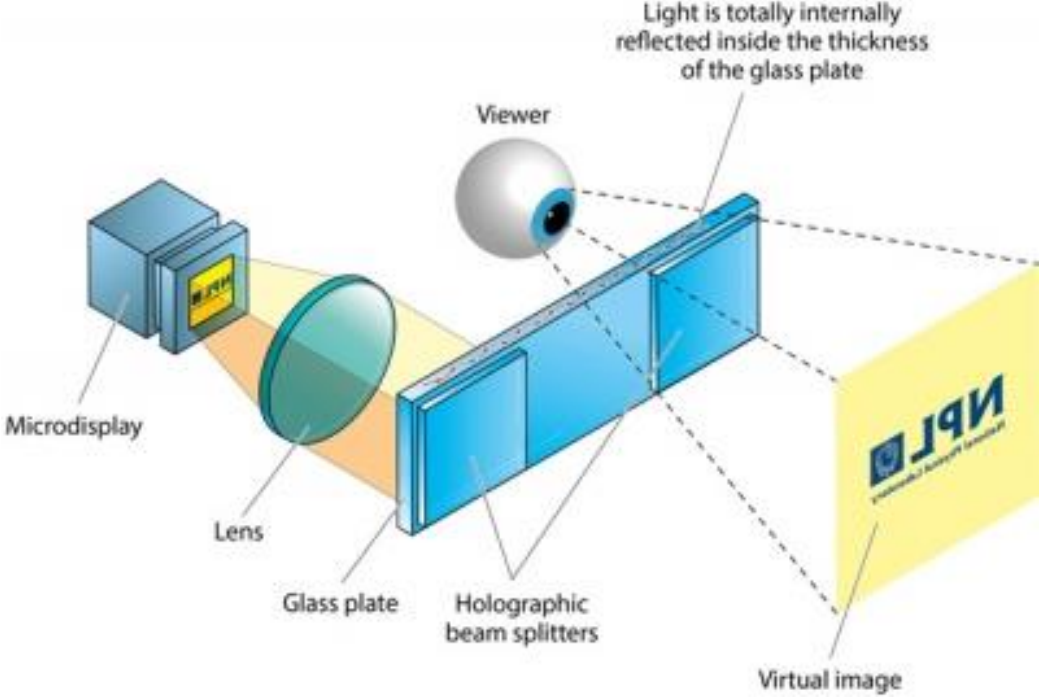
META[®]
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metaAIR[®] Laser Glare Protection Eyewear

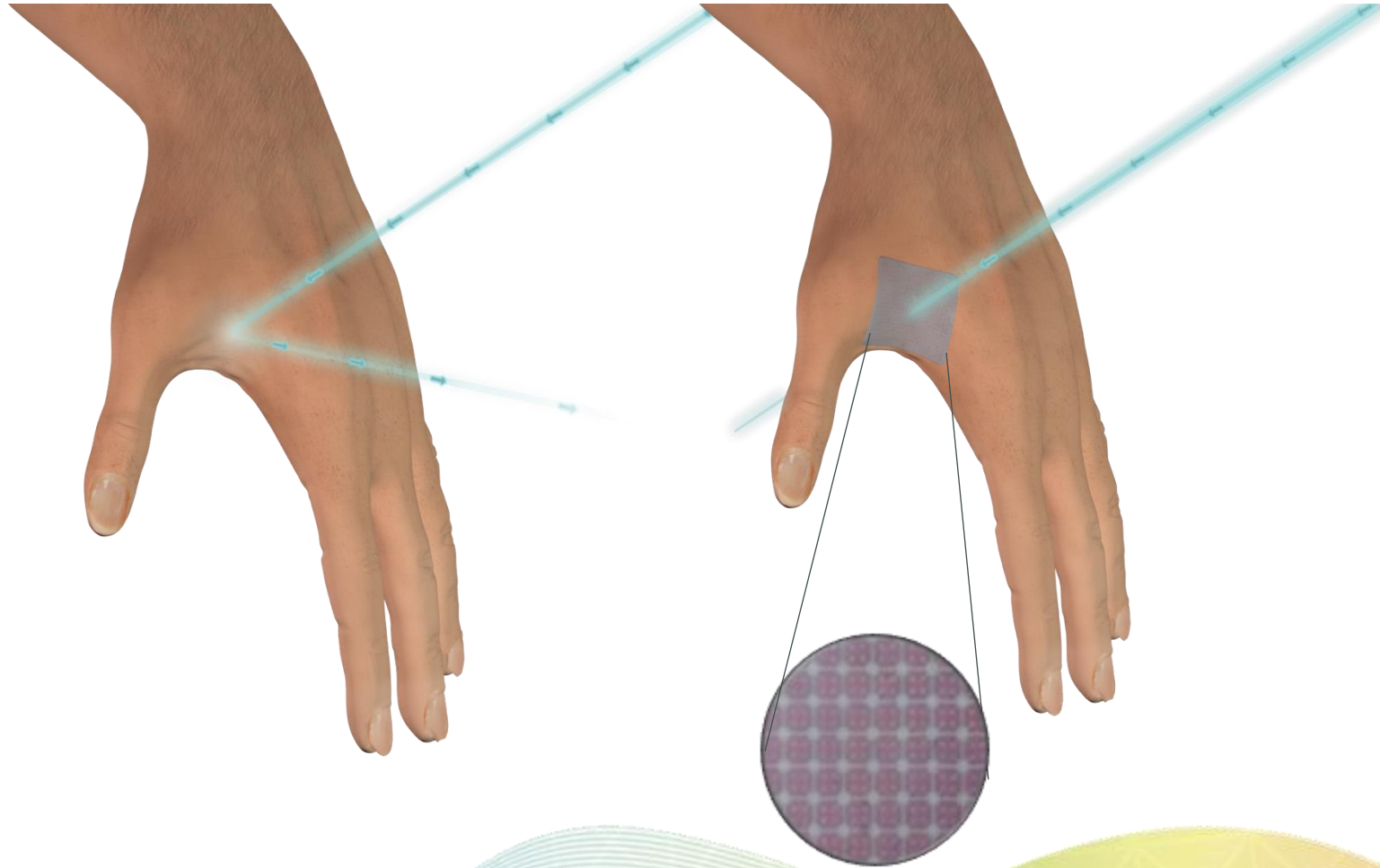
META[®]



Augmented Reality



Biosensing w/ Impedance Matching



Wearable Biosensor Vision



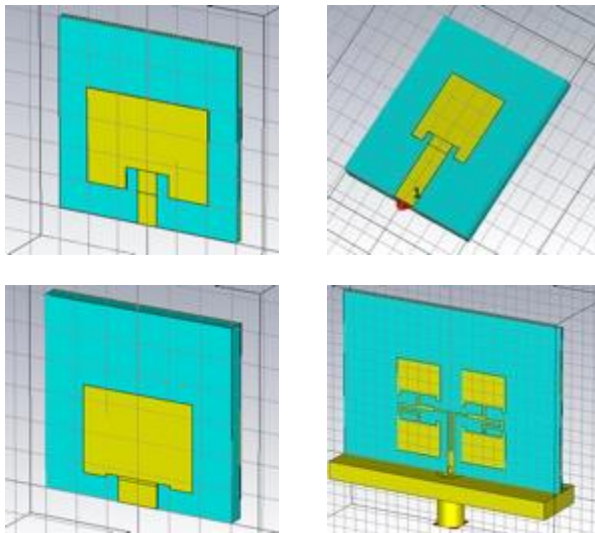
Secure Currency & Brand Protection

- Produce motion, depth and color without inks or dyes.
- Full color, nearly impossible to reproduce.
- Engaging security features with RGB color, 3D images, and movement.
- Developing new security feature for a confidential top-10 central bank.



NANOWEB® Antennas

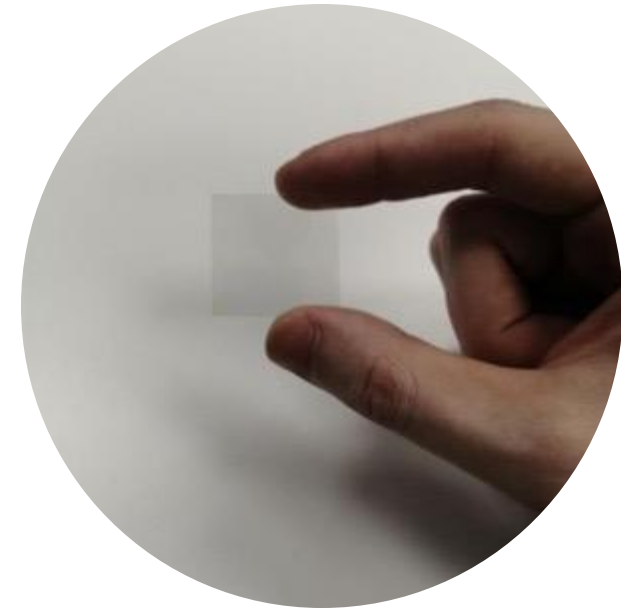
Custom Design & Simulation



Precision Fabrication



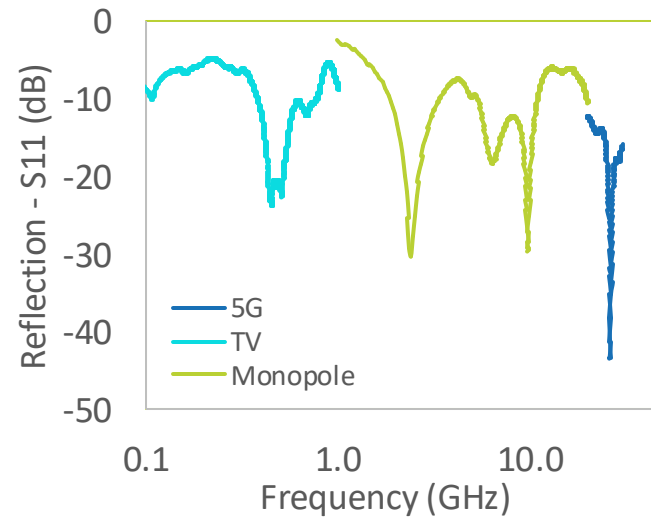
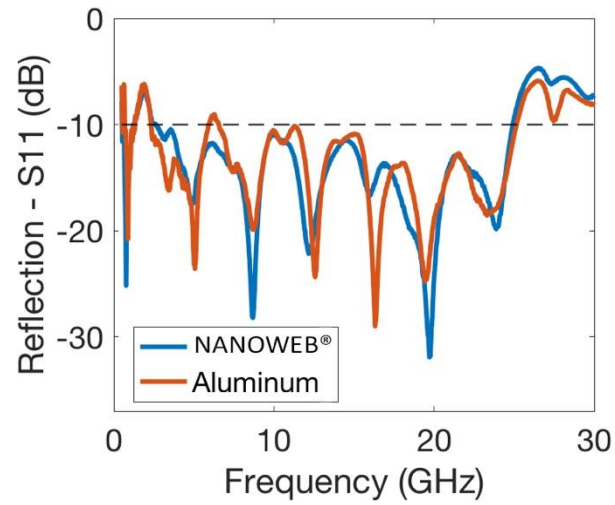
High Performance & Transparency



NANOWEB[®] Antennas



Integrate high-speed communications functionality while maintaining visibility



Transparent Microwave Doors

META[®]

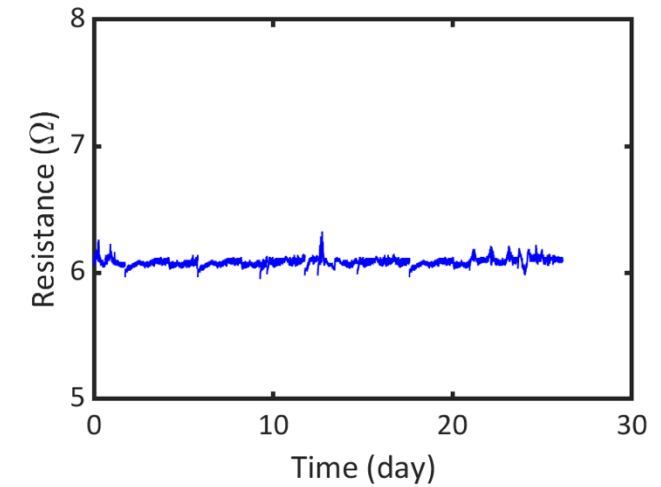
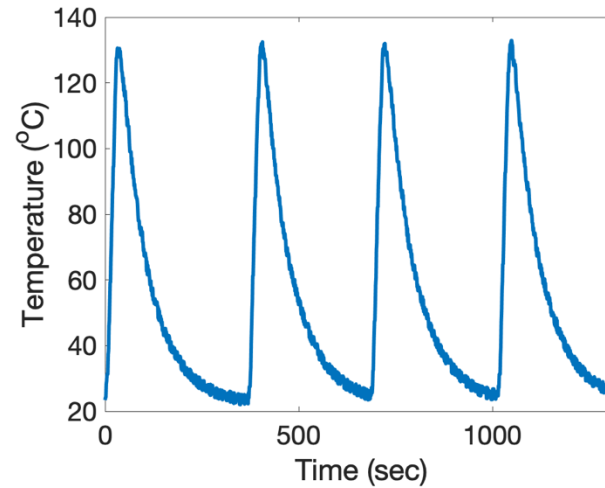


EMI Shielding & Nano-heater to Protect Sensors - Transparent to RADAR and LIDAR Simultaneously

META[®]



NANOWEB® Temperature Cycling



Heating performance tests using NANOWEB®

Each 25-second-long heating pulse raises the temperature of the 1mm thick glass substrate by 100 °C. The test has been conducted in a constant temperature chamber using 95% transparent NANOWEB®.

Focus Application

Transparent Redirectors for Communications

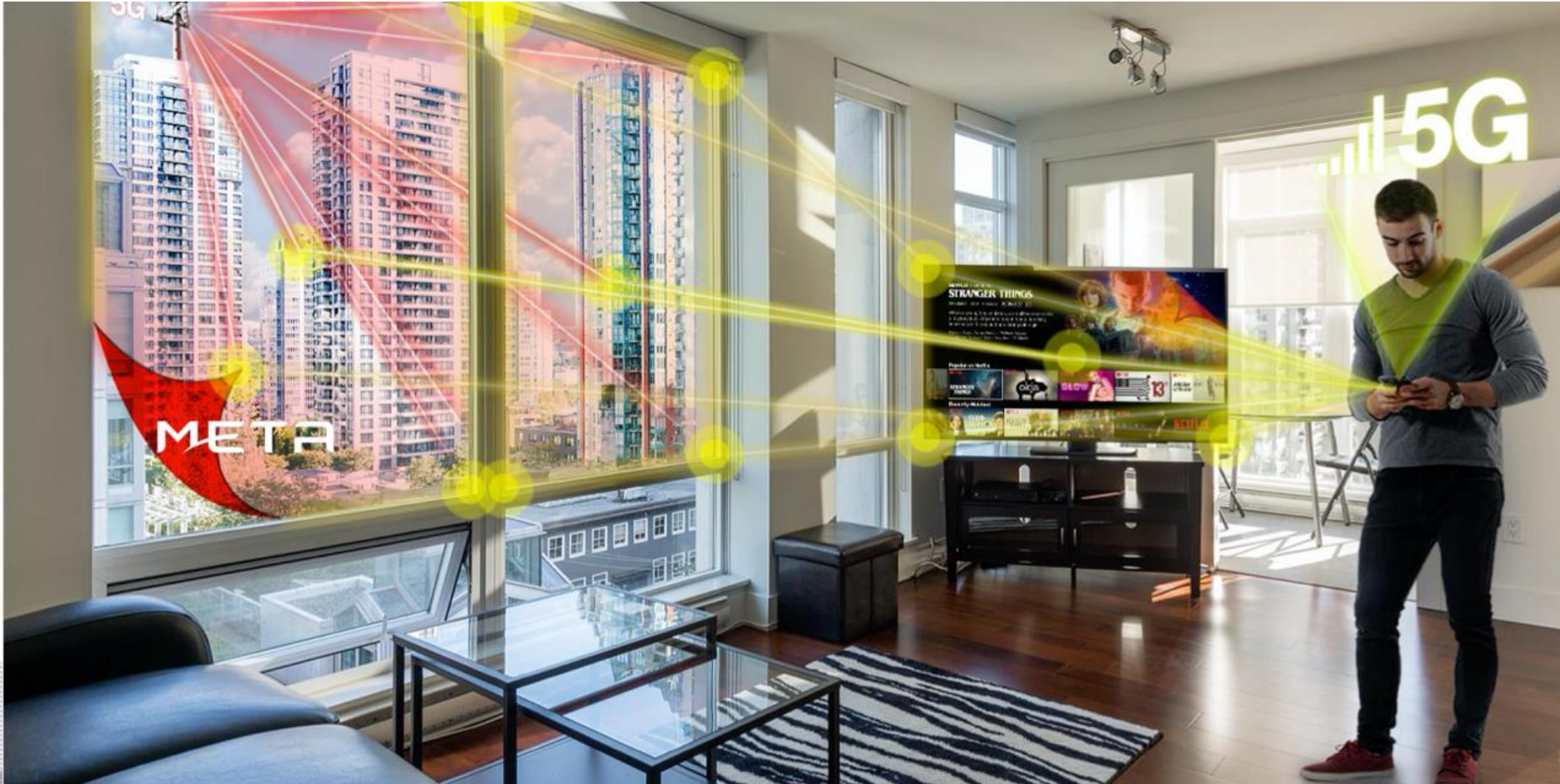
META[®]
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Outdoor 5G Coverage Enhancement

META[®]



Indoor Coverage Enhancement



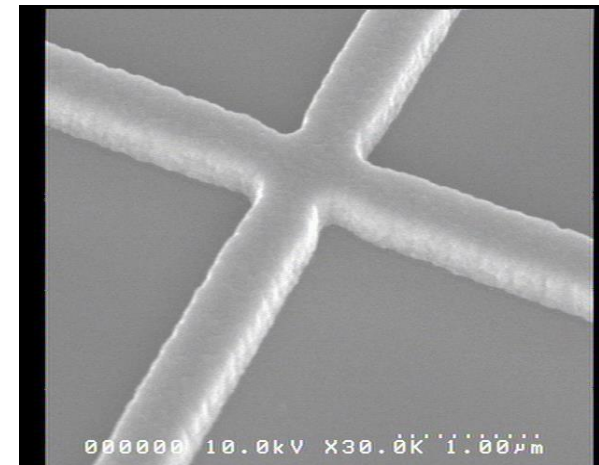
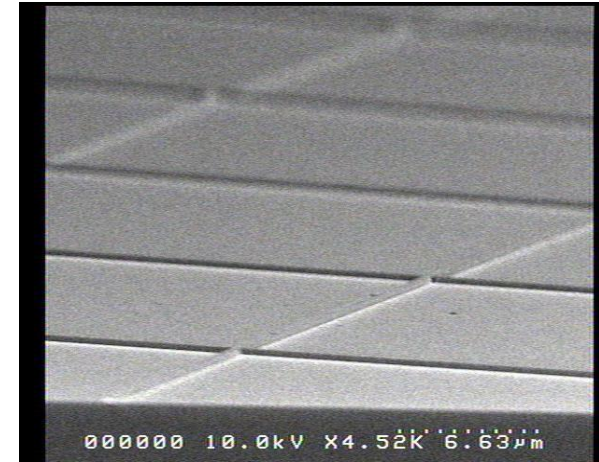
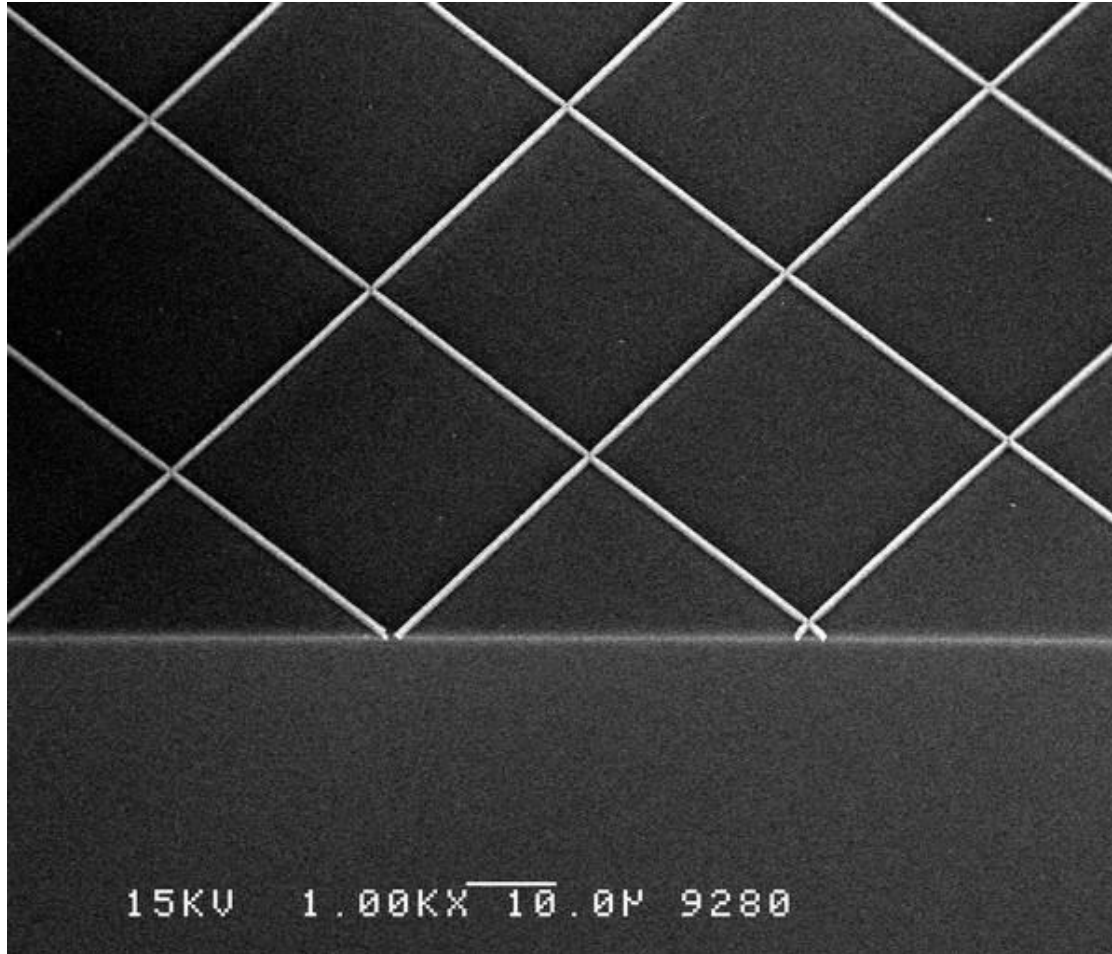
Technology

Nanoweb Metal Mesh

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NANOWEB[®] – Transparent Metal Mesh

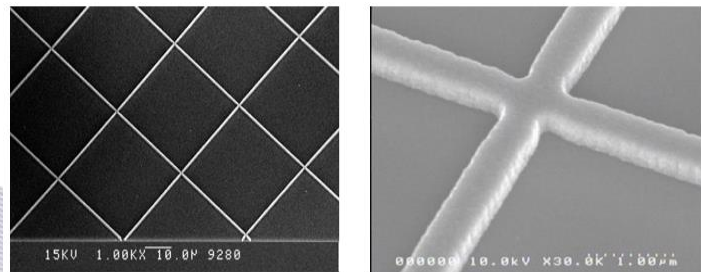
META[®]



Nanoweb Comparison

Sub-micron, high transparency, super conductive metal mesh

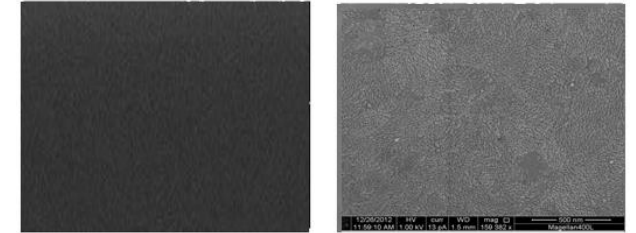
- ✓ Higher Transmission >95% Vs. Conductivity 1-20 Ω /sq
- ✓ Low Haze 1-2%
- ✓ Hi Resolution & Control
- ✓ Flexible substrates or directly on Glass, Sapphire



VS.

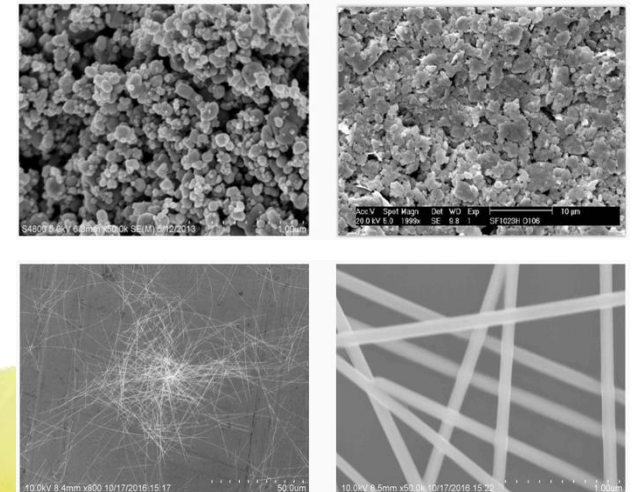
- ✗ Lower Transmission Vs. Conductivity
- ✗ Not flexible
- ✗ Not suitable for large surface areas

ITO



Silver flakes & Nanowires

- ✗ High Haze
- ✗ Lower Transmission
- ✗ Lower Conductivity
- ✗ Lower precision

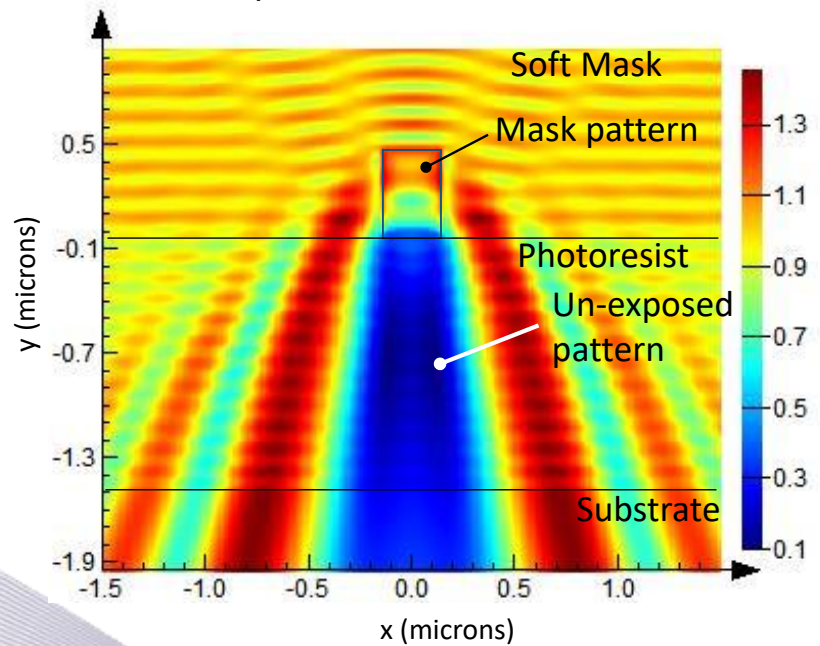


Optimizing NANOWEB®

Translate requirements into designs, develop new masks tailored for optimum performance of target applications.

Linewidth Pattern optimization

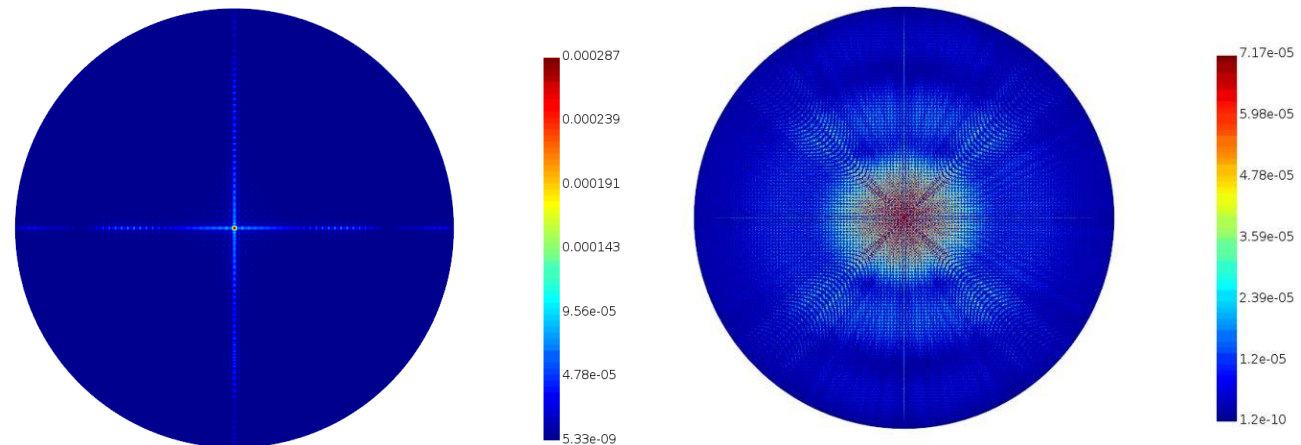
Colormap for the E-Field Distribution



High contrast enables high uniformity and yield

Haze and Transmission optimization

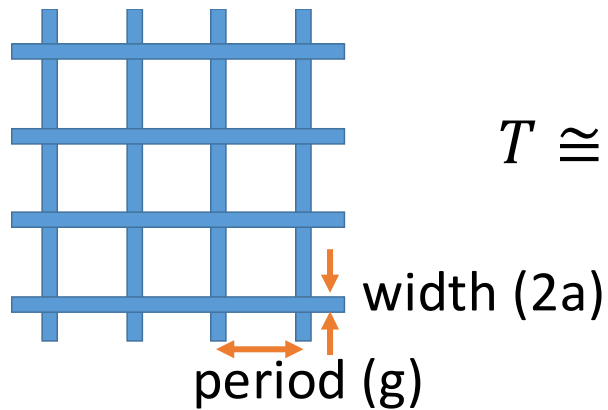
Polar maps for the scattered field



Haze, diffraction and transmission can be optimized for each application

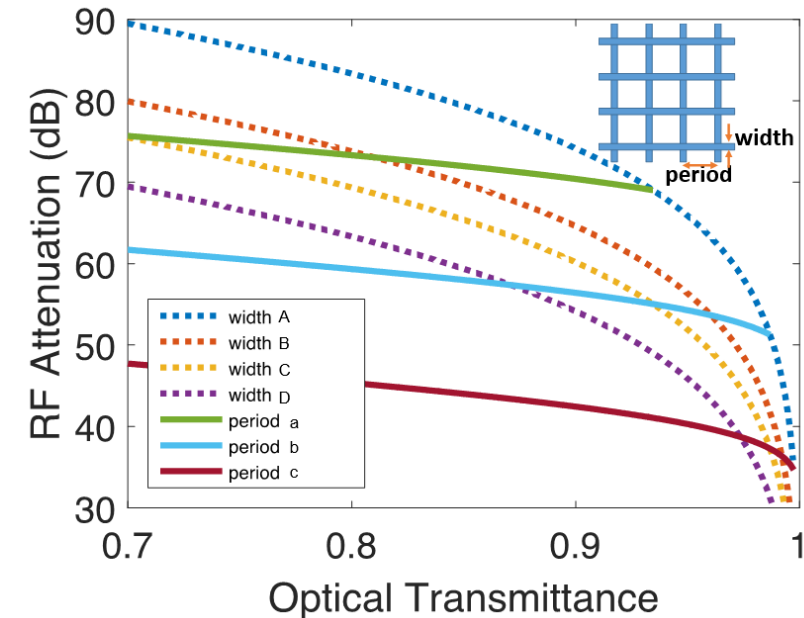
EMI Shielding - Optimum set of design parameters

Analytical Model for the RF Transmission



$$T \cong \frac{4g^2}{\lambda^2} \left[\ln \left(\sin \frac{\pi a}{g} \right) \right]^2$$

RF attenuation at 3 GHz vs. Optical Transmittance



Smaller width has higher EMI shielding

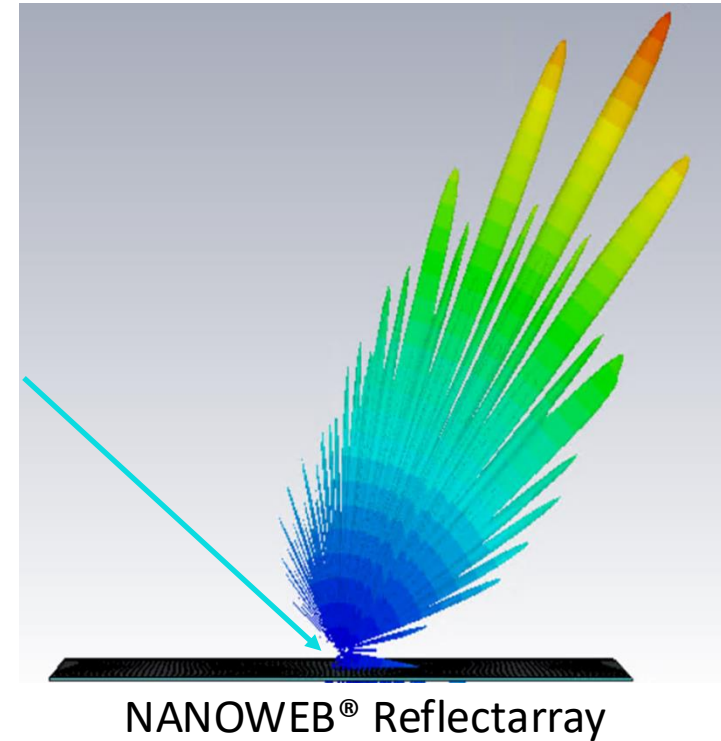
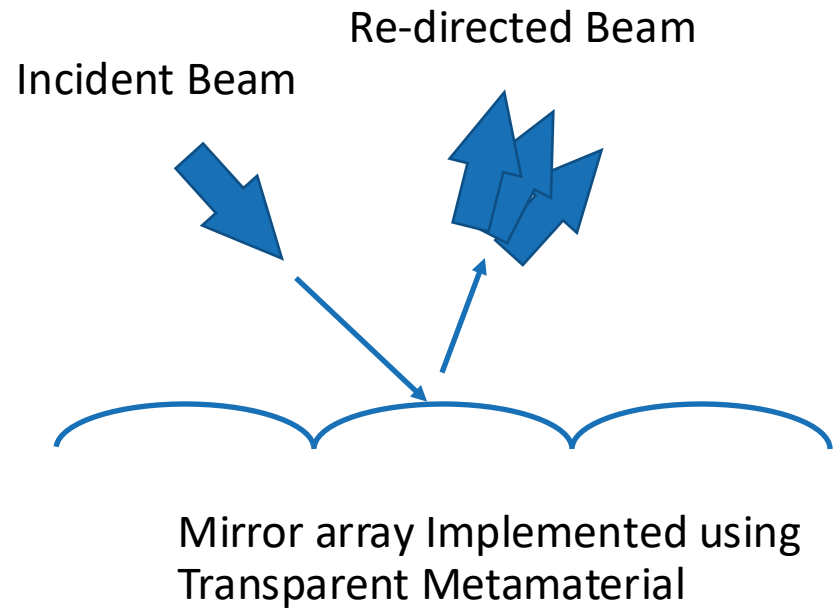
GOAL : Finding optimum width, period and thickness of the Nanowires for largest EMI Shielding

Solution

Transparent Metasurface Reflectarrays

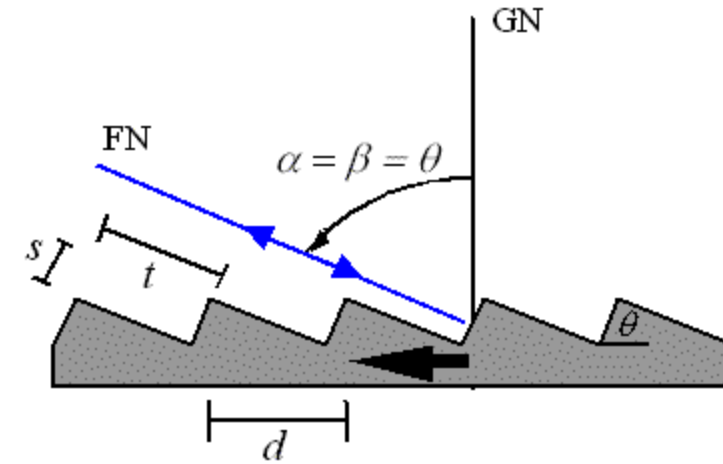
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Key idea: Geometric Optic Analogue of a Beam Disperser



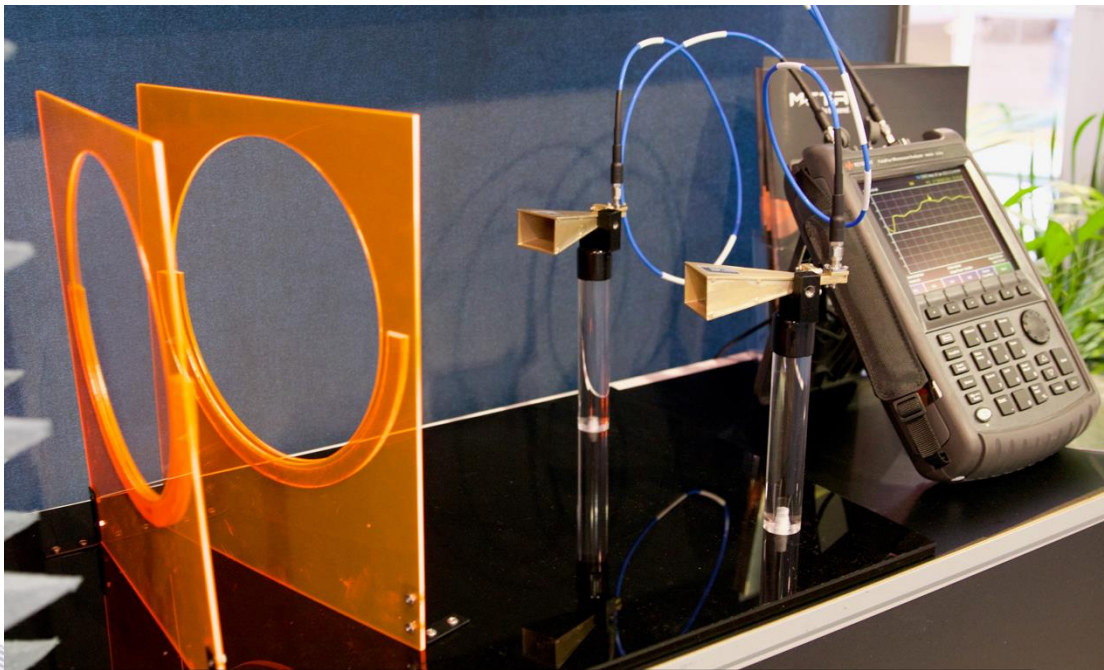
Design Overview

- Reflectarrays based on square patches
 - The localized reflection phase can be controlled by changing patch size
 - Parabolic mirrors and Eschelle grating type surfaces can be implemented
 - Beam broadening or deflection
 - High efficiency (~92%)
 - Polarization Insensitive operation
 - Wideband design

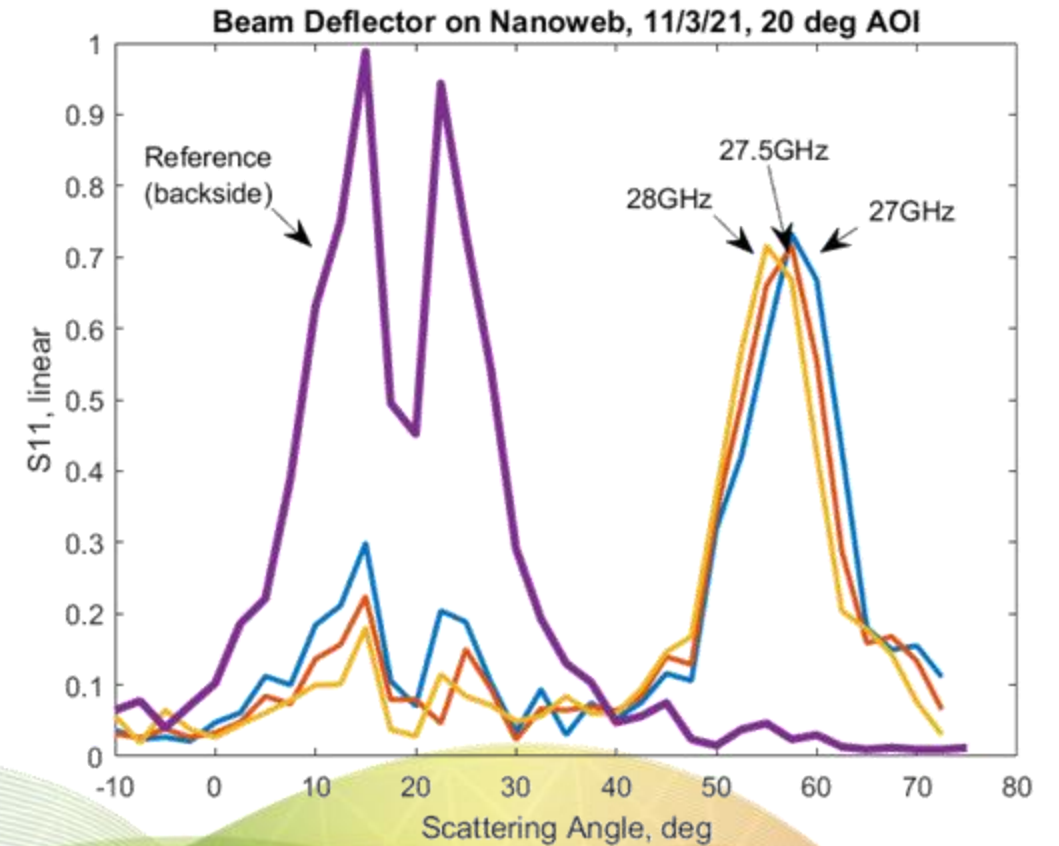


Implementation for Anomalous Reflection

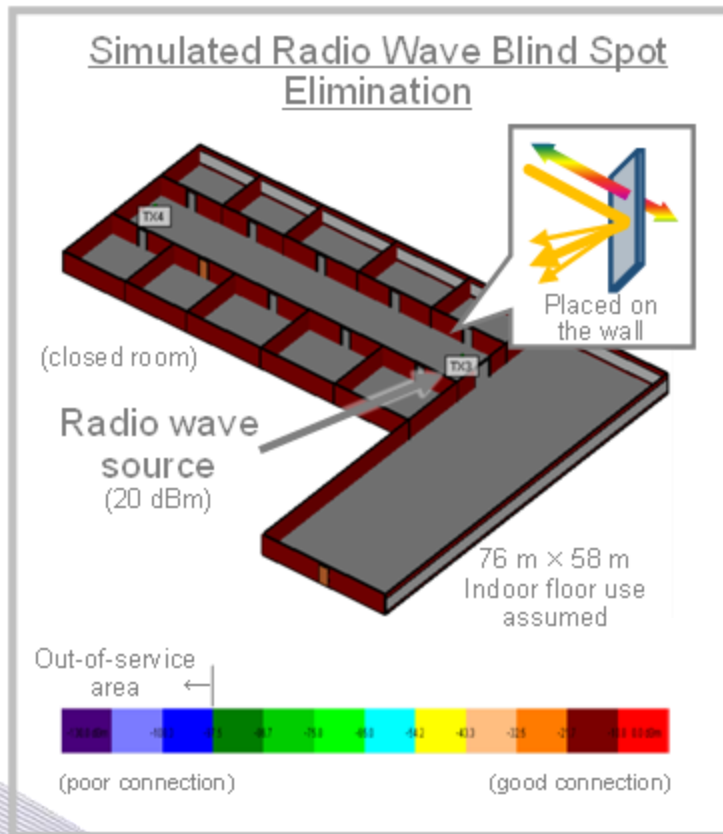
Fabricated Film in Demo Setup



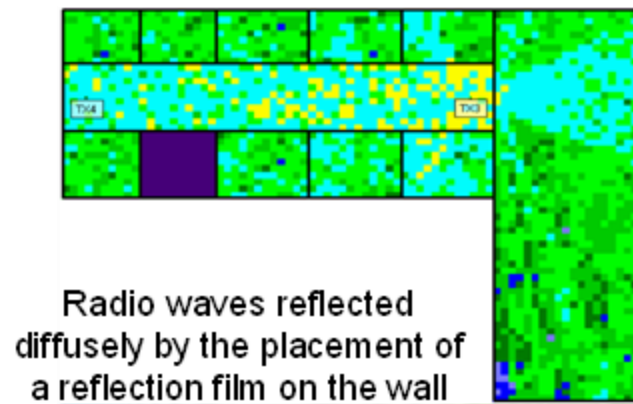
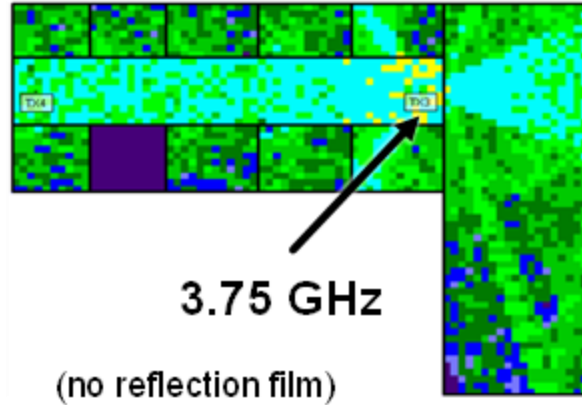
-20 Deg Angle of incidence



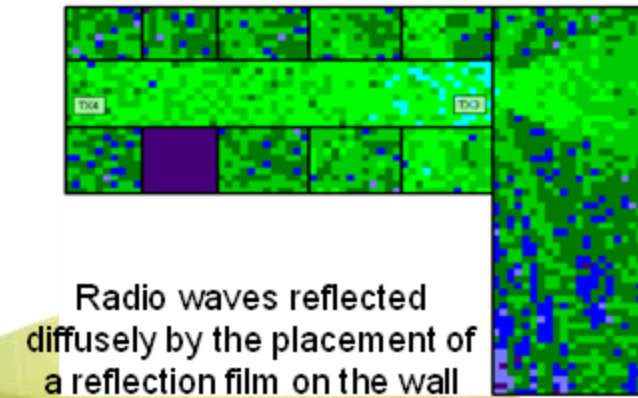
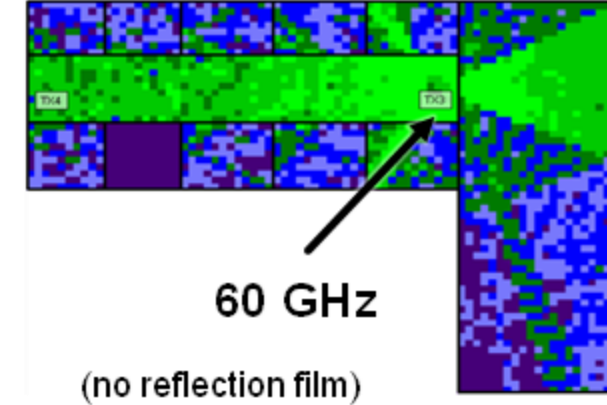
Simulation of Indoor Coverage Enhancement



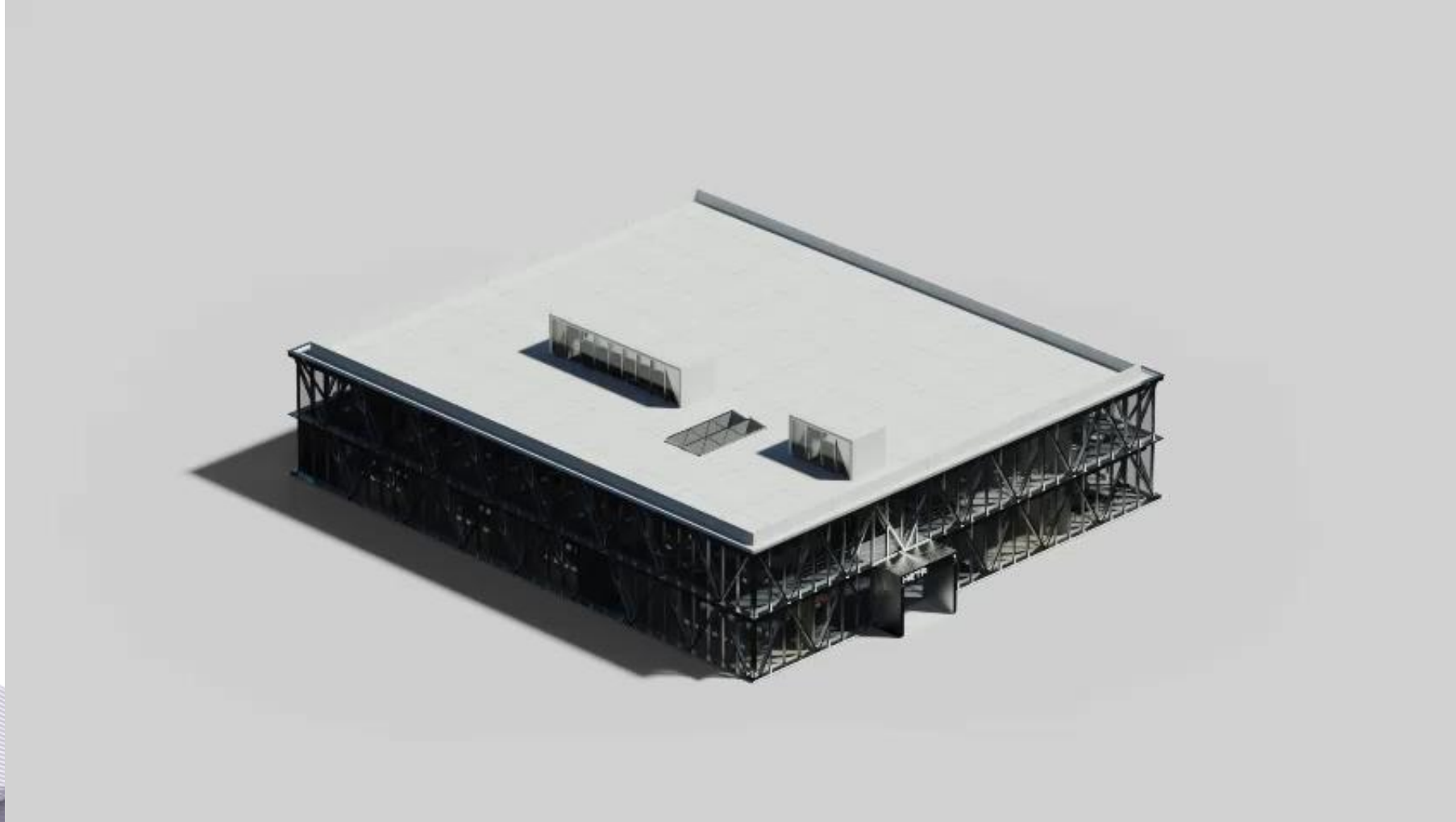
<5G Frequency Range>



<Prospective Beyond-5G Frequency Range>

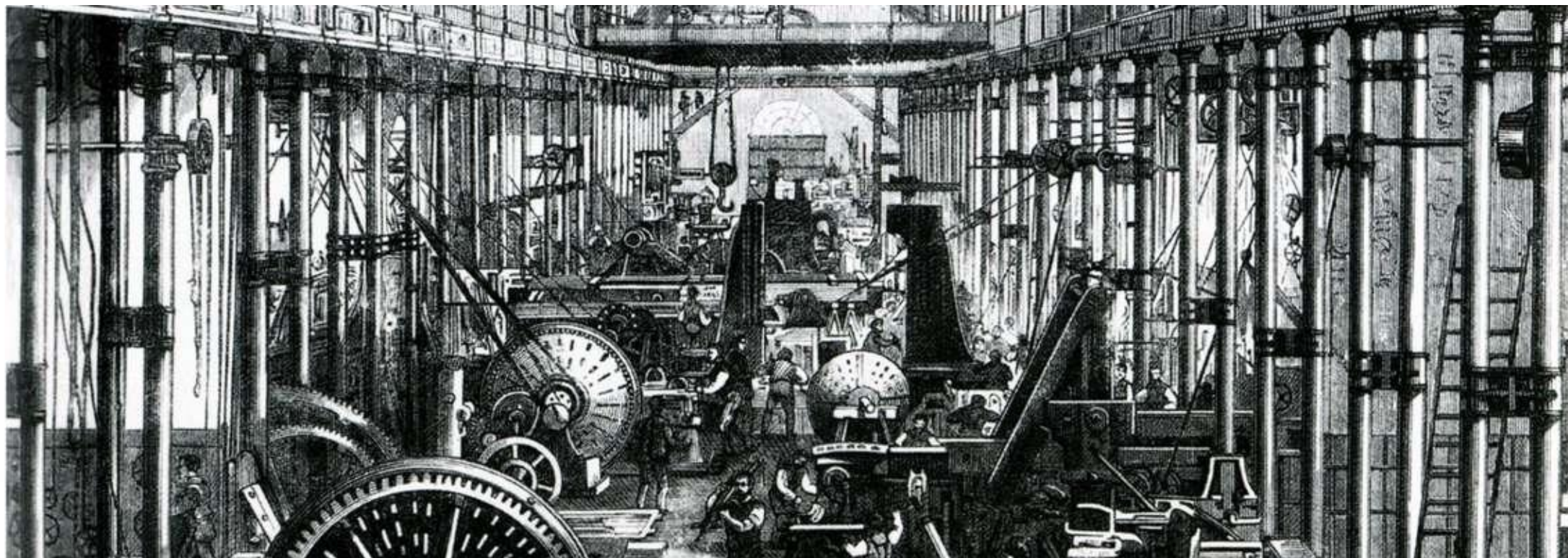


Indoor Coverage Enhancement



Manufacturing at Scale

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1950s

Silicon
Transistor



1
Transistor

1960s

TTL
Quad Gate



16
Transistors

1970s

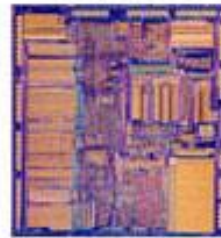
8-bit
Microprocessor



4500
Transistors

1980s

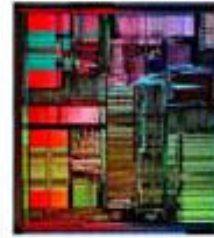
32-bit
Microprocessor



275,000
Transistors

1990s

32-bit
Microprocessor



3,100,000
Transistors

2000s

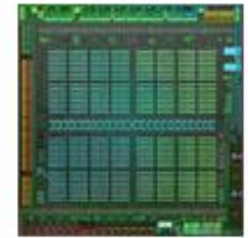
64-bit
Microprocessor



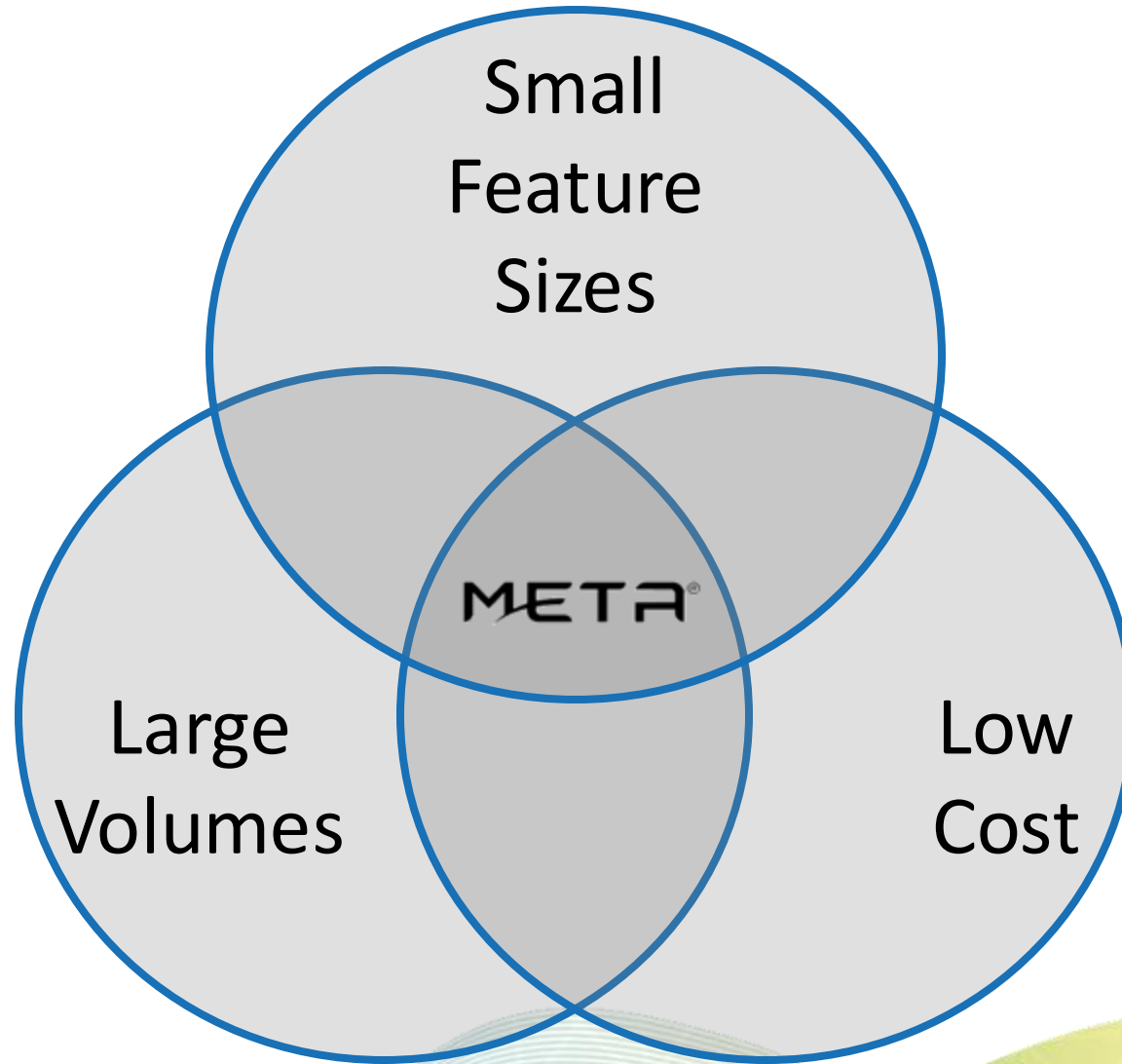
592,000,000
Transistors

2010s

3072-Core
GPU



8,000,000,000
Transistors



How to Fabricate Fast?

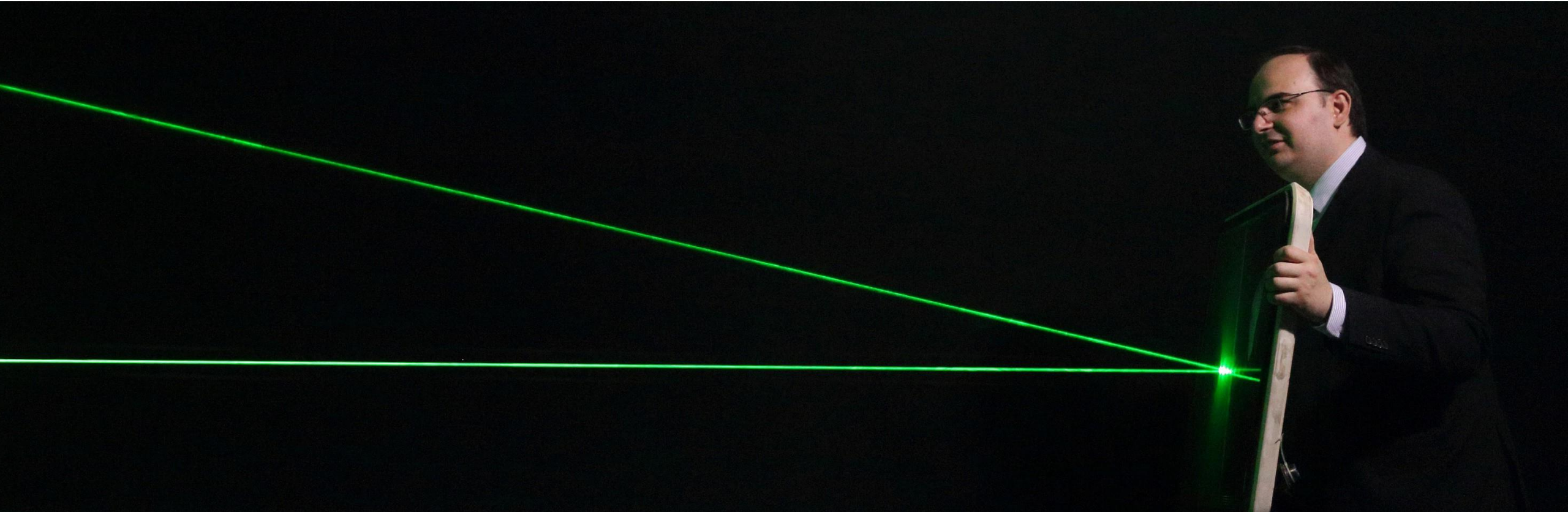
META[®]
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Large-Scale Manufacturing Techniques

- Scanning Holography
- Rolling Mask Lithography
- Nanoimprint Lithography

metaAIR®

META®

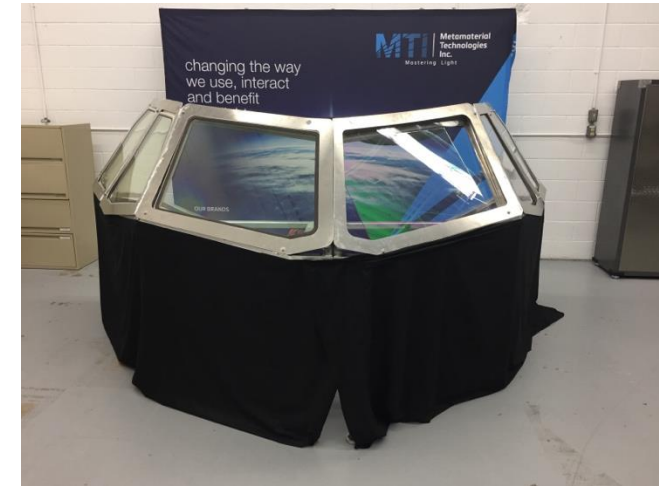


Aircraft Windows

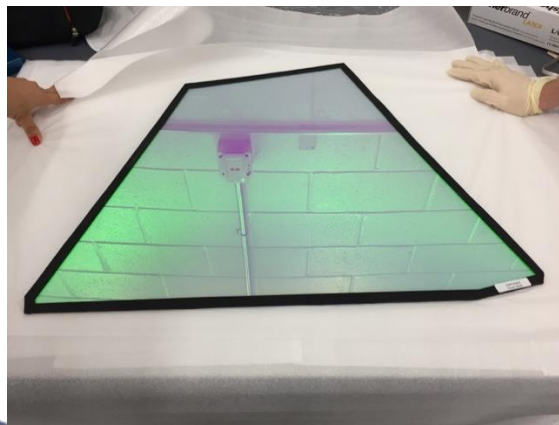
metaAir on sliding window of Airbus A319 (binocular view)



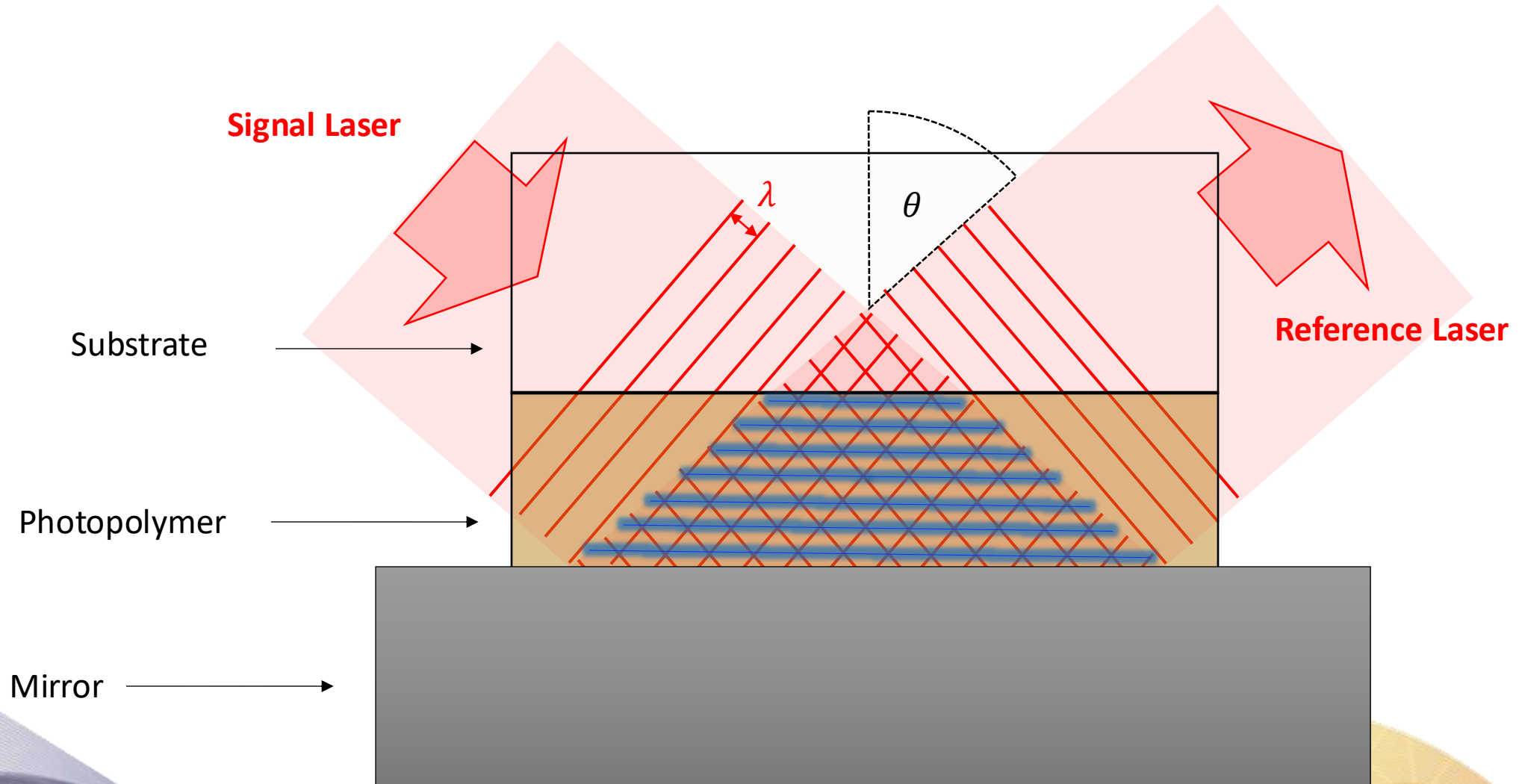
metaAir on 6 windows on Airbus A320 cockpit mock-up



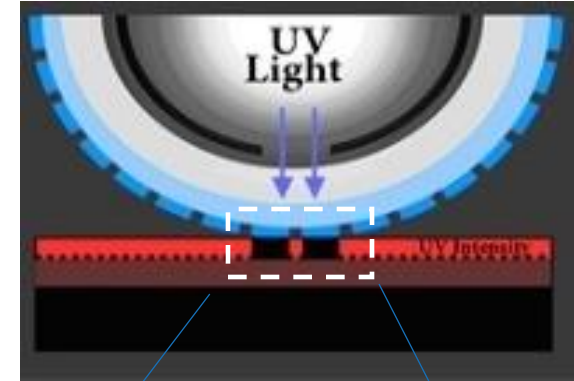
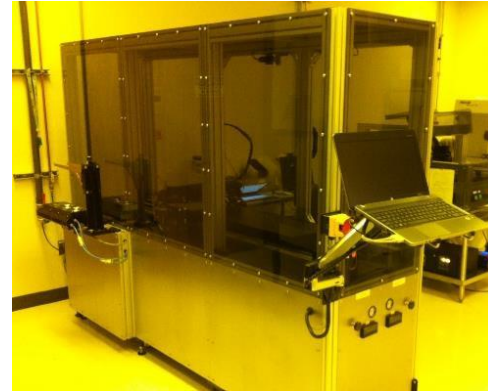
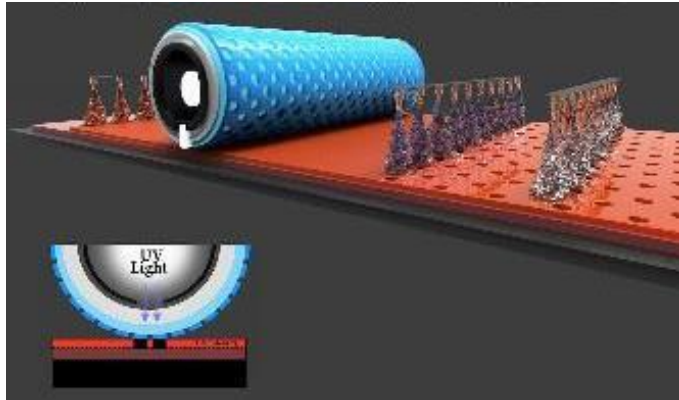
metaAir for A320 sliding window



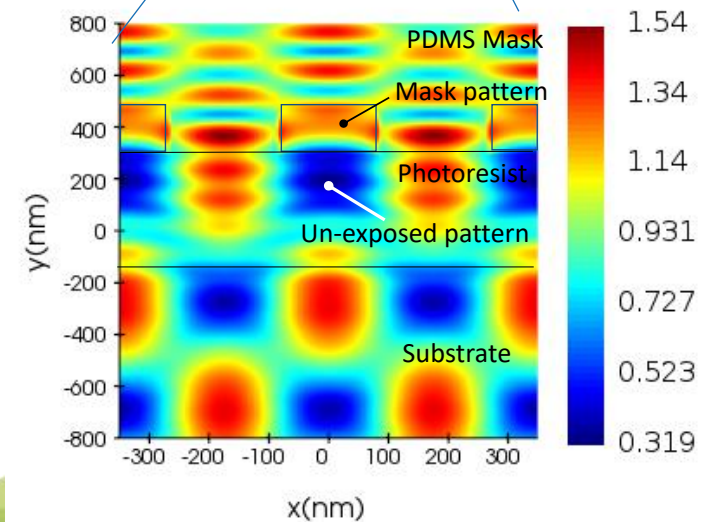
Making a mirror for a laser using a mirror and a laser



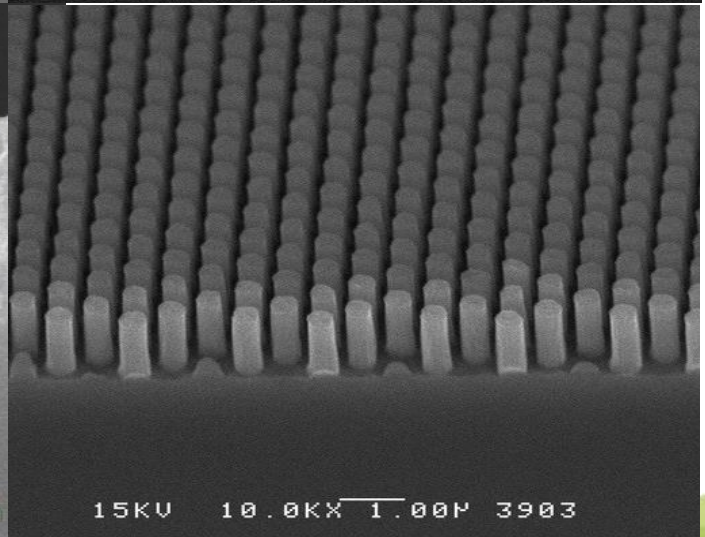
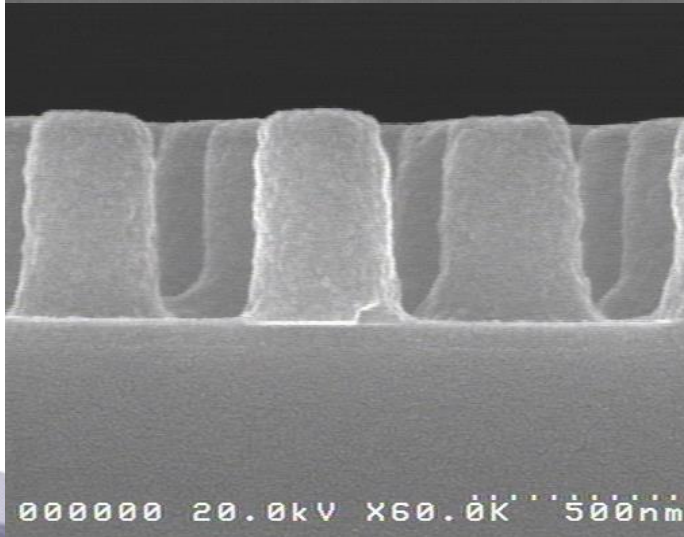
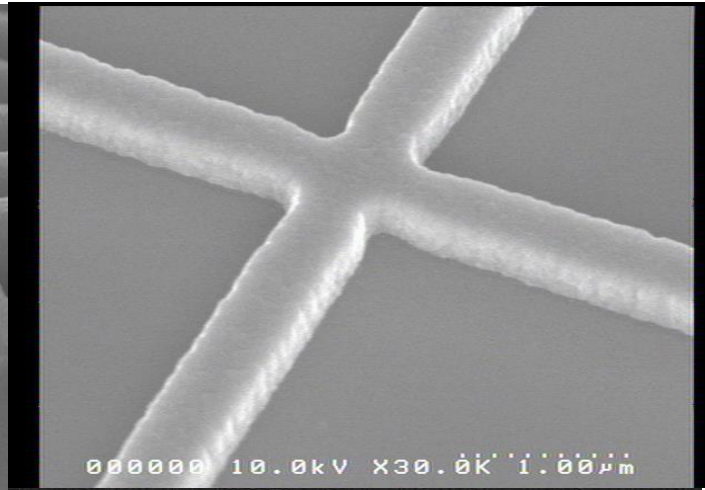
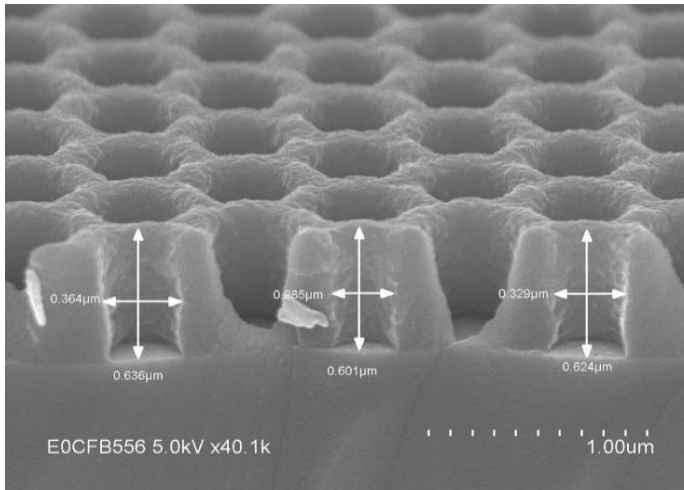
Rolling Mask Lithography (RML[®])



- Continuous and scalable
- Inexpensive
- Ultra-fast fabrication
- Phase lithography
- RML[®] proprietary tool
substrate size: 1m x 0.3m
- Resolution: 150nm
- Capacity: 3m/min
- vs. amplitude lithography: smaller feature sizes
 - Diffraction limited, 5 μ m for far field (at volume)
- vs. NIL: no residuals, enables liftoff/additional layers (at larger feature sizes)

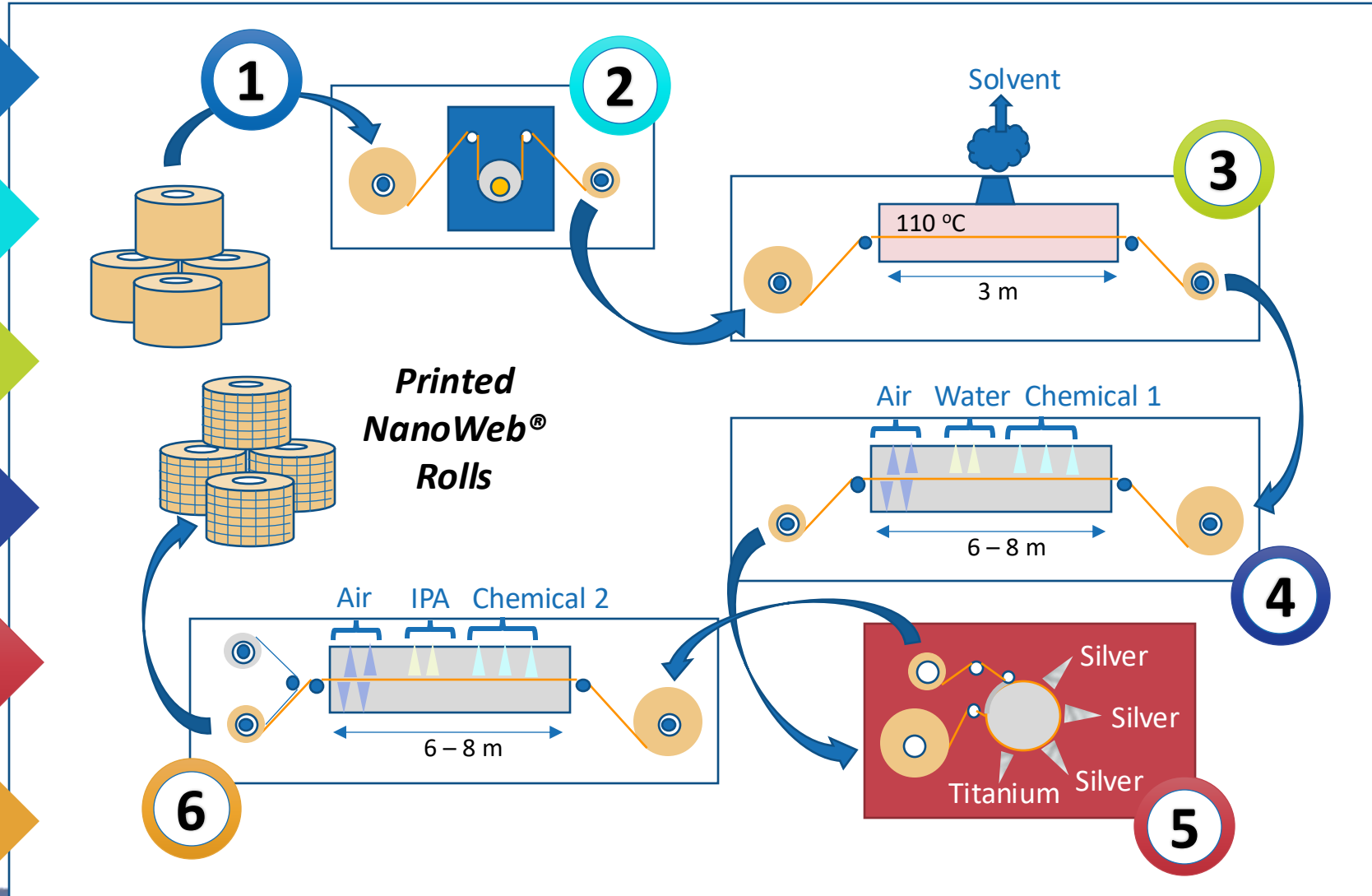


Made with RML[®]

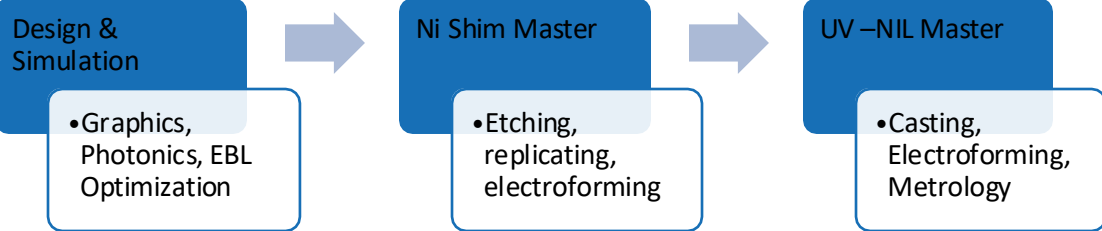


R2R Rolling Mask Lithography

- 1 Loading**
Pre-coated PET film with bi-layer photoresists.
- 2 Exposure**
Printing with RML technology using UV-365nm and proprietary mask
- 3 Baking**
Stabilizing chemistry of printed design in photoresist.
- 4 Development**
Creation of 3D structures in Photoresist.
- 5 Metallization**
Metal in deposition to create continuous metal mesh.
- 6 Lift off and Protection**
Removal of unwanted material and protection of mesh prior to re-winding.



Nanoimprint Lithography Workflow



Electron beam lithography



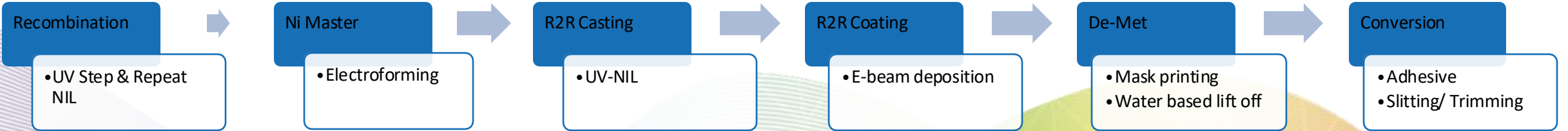
Step-and-repeat Nano-imprint lithography



Recombined Ni Shim



Plasmonic full parallax display foil product



R2R UV-NIL Line - Industrial Foil Production Process

- Ultra high-resolution replication: nanometer scale
- Wide Web Embossing: up to 1200mm
- High speed: up to 150 m/min
- Ni Working Shims
- Cold UV Lamps







Thank You

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META[®]
Go Beyond.

